Exam Materials Science

January 30, 2023, 8:30 - 10:30 Exam Hall 1 Blauwborgje 4

- Separate Exercise 1 sheet from others, write your name and s-number on the top, mark correct answers and use it as your first answer sheet.
- *Make the exercises 2 to 4 each on a separate two-sheets paper.*
- Clearly indicate your name and student number on each separate sheet of paper.
- Indicate on the first sheet the total number of papers you hand in.

Mark for the exam = 1 + 9*((sum of total points scored) / (max. number of points (65))

Suggestions:

- Work fast and write down answers concisely.
- When you have difficulty to find an answer and to formulate it, do not keep on thinking for a long time, but move to the next question. Then, come back to this (skipped and unanswered) question later when you still have time.

Exercise 1: Quiz (15p: maximal number of points 30 divided by 2) Mark by cross the correct answer(s). Separate this page from others, write your name and snumber on the top and use it as your first answer sheet.

- 1. What is the highest number of covalent bonds that Carbon atom may offer?
 - \square_3
 - \mathbf{X}_4
- 2. What value of electrical conductivity would you expect for solid having dominantly:

	high	low
metallic bonding	x	
ionic bonding		X
covalent bonding		х

- 3. Grain boundary is 2D structural defect existing in:
 - amorphous material
 - \Box single crystal
 - X polycrystalline material
- 4. Sort different arrangements of atoms in solids, according to value of atomic packing fraction!

	high	middle	low
face centred cubic	x		
body centred cubic		X	
close packed hexagonal	х		
amorphous			х

5. Typical precipitation hardening process consists of following subsequent steps:

 \boxtimes 1. Heating at higher temperature; 2. Fast quenching; 3. Heating at lower temperature

1. Fast cooling from liquid state; 2. Heating at middle temperature

1. Long-time heating just under eutectoid temperature; 2. Fast quenching

- 6. Polymers are exclusively synthetic materials formed by additional or condensation polymerization.
 - true
 - ⊠ _{false}

7. Indicate typical mechanical characteristics for three different groups of materials:

	Stre	ngth	Duct	ility	Young's mod.			
	High	Low	High	Low	High	Low		
Ceramics	X			Х	X			
Metals	x		Х		Х			
Plastics		х	х			Х		

8. Classify following defects in solids according their dimensionality!

	point	linear	planar	volume
surface crack	Î		Î	X
vacancy	Х			
stacking fault			X	
edge dislocation		×		
interstitial atom	x			
grain boundary	Π	Π	X	Π
grani boundary	П			
precipitate				ث

- 9. We observe a huge difference in electrical conductivity in different types of materials? It is mainly due to a large difference in:
 - \boxtimes density of their free charge carriers

 \Box size of electric charge of their charge free carriers

mobility of their free charge carriers

- 10. The size of the energetic band gap between the Valence and the Conduction band in insulators <u>is</u> typically:
 - $\Box \sim 1 \text{ eV}$
 - X > 3 eV

and may be any value because the position of Fermi energy level is important

- 11. The presence of dielectric material between plates of a capacitor in comparison with the vacuum between them:
 - decreases its capacity
 - increases its capacity
 - has no influence

Exercise 2 (15p)



Attached figure shows a part of Fe-Fe₃C phase diagram, the base of steel.

- a) Name all the areas in this phase diagram that contain only a single phase. (2p) These are: area with liquid phase L and 3 areas with solid phase: δ , γ and α . (1/2p for each named area)
- b) We have an Fe-C alloy with 2 wt.% C slowly cooling down from 1 600 °C to room temperature. At what temperature does the first (tiny amount of) solid form? Give the composition (value) of this solid. (2p)

About 1380 °C, clearly above 1360 and below 1394 °C. The composition is about 0.8 wt.% C (0.7 and 0.9 can be accepted, but not outside this range). (2p)

- c) At what temperature does the last liquid drop disappear in this 2 wt.% C alloy upon further cooling? What is the composition (value) of this last liquid? (2p) About 1180 °C (plus min max 10 °C). About 4.0-4.2 wt.% C. (2p)
- d) Suppose a Fe-C alloy with a certain amount of C is cooled down to 728 °C. Only austenite and cementite phases are observed, and the weight fraction of austenite is measured to be 0.9. What is the concentration of C in the alloy? Show how you compute your answer. (2p)

Using the lever rule at 728 °C: 0.9 = (6.7 - x)/(6.7 - 0.76) or also 0.1 = (x - 0.76)/(6.7 - 0.76), which both lead to x = 1.354 wt.% C. (2p)

e) At what temperature will the eutectoid pearlite be formed from austenite? Compute the fractions of the phases present in pearlite. (3p)
At temperature just below 727 °C (1p). Pearlite fractions: α = (6.7 - 0.76)/(6.7 - 0.022) = 0.889 (1p), fraction Fe₃C = (0.76 - 0.022)/(6.7 - 0.022) = 0.111. (1p)

f) Cold rolling and after annealing can be used to strengthen low Carbon steels. Explain how cold rolling can strengthen the steel (1p). Why can it be necessary to anneal cold rolled steel? (2p) Still, also few various cycles of cold-rolling and recrystallizing the steel can be strengthened compared to the original material. Explain how this is possible. (1p) Cold rolling increases strength, because it increases the dislocation density and since dislocations are mutual obstacles during their movement, it also decreases dislocation mobility and thereby increases (yield) strength. (1p)

Cold rolling creates texture and this leads to anisotropic properties (i.e. properties are not the same in different directions. This is often not acceptable. (1p) Annealing leads to recrystallization and thereby it removes texture and anisotropy. (1p)

Cycles of cold rolling and recrystallization generally are used to refine the grains of the material. Smaller grain size leads to relative more grain boundary density (per unit volume) and since boundaries are obstacles for dislocations movement, it decreases dislocation mobility and thereby increases (yield) strength. (1p)

Exercise 3 (16p)

We have a crane whose vertical arm has a cross-sectional area of $5x5 \ cm^2$, and a length of $5 \ m$. This arm is loaded parallel to its length. We know that it behaves according to linear elasticity for the regime we are working. The manufacturer told us that this behavior will stop when the load exceeds 100 000 kg, i.e. 100 tons. This load will produce an elongation of the arm of the crane of $1 \ cm$.

(2p)

- a) Calculate the yield strength of the material. (2p) $\sigma_y = \frac{F}{A} = \frac{100\ 000\ kg}{25\ cm^2} = 4\ 000\ \frac{kg}{cm^2} = 4\ 000\ x\ 9.81\ N/(0.01x0.01)m^2 \approx 400\ MPa$
- b) Calculate the yield strain of the crane arm material. (2p) $\varepsilon_{\parallel} = \frac{\Delta l}{l} = \frac{0.01 \, m}{5 \, m} = 0.002 = 0.2 \,\%$ (2p)
- c) Calculate the Young's modulus of the crane arm material. (1p) $\sigma = E \cdot \varepsilon_{\parallel} \implies E = \frac{\sigma}{\varepsilon_{\parallel}} = \frac{400 MPa}{0.002} = 200 GPa \quad (1p)$
- d) If the Poisson ratio is 0.3, calculate in terms of percentage the reduction in cross-sectional area due to a loading of 100 000 kg. (3p)

 $((1 + \varepsilon_{\perp})^2 - 1^2) * 100 \% = (2\varepsilon_{\perp} + \varepsilon_{\perp}^2) * 100 \% \approx 2\varepsilon_{\perp} * 100 \%$ $\varepsilon_{\perp} = -\nu \cdot \varepsilon_{\parallel} \Rightarrow 2\varepsilon_{\perp} * 100 \% = 2 * (-0.3) * 0.002 * 100 \% = -0.12 \%$ The minus means the reduction of cross-sectional area. (3p)

e) What happens both on a macroscopic and an atomic scale in the metal when the load exceeds yield strength? Each of the two answers is possible in one sentence. (4p)
On a macroscopic scale the length of the arm will increase permanently after the loading beyond yield strength, because of plastic deformation. (2p) Up to yield strength the loading is fully elastic.

On an atomic scale the plastic deformation normally means that atomic planes start sliding with respect to each other. (2p) This sliding occurs by the movement of dislocations.

f) Would it make a difference for the mechanical behavior of material near yielding if it has a crystalline or an amorphous structure? Motivate your answer. (4p)

Yes, it makes a large difference, because in crystalline systems plastic deformation and thus strengthening can occur by sliding of crystal planes with respect to each other. (2p)

In amorphous materials slip along planes is impossible (there are no planes) and therefore such materials are very resistant to plastic deformation (are very hard), but also very brittle (very low fracture toughness) and cannot be used with any reliability under tensile loading. (2p)

Exercise 4 (19p)

- a) At room temperature, the resistivity of diamond is 10^{20} times higher than the one of pure Ag. Explain how this is possible and which physical quantity is responsible for it. (2p) For the conductivity in case of electron conduction it holds: $\sigma = n|e|\mu_e$. The huge difference in resistivity (1/conductivity) between diamond and Ag is caused by the huge difference in *n*, i.e., the number of free electrons, i.e., conduction electrons. (1p) This difference is caused by the strong localization of electrons in diamond, i.e., each valence electron is really strongly bound to its own carbon atoms such that *n* is extremely low, whereas in a metal like Ag, each atom donates at least one electron to a sea of delocalized electrons which can move relatively freely throughout the material giving a very high *n*. (1p)
- b) What will happen to the difference in resistivity of these two materials if the temperature is increased for example to 300 °C? Explain this by discussing how temperature affects the resistivity of both discussed types of materials. (4p)

This huge difference will reduce (1p), because for semiconductors or insulators the resistivity decreases with increasing temperature, whereas for metals it will increase. (1p) The reason for decreasing resistivity of diamond is that the number of free charge carriers (conduction electrons) will increase, because more electrons obtain now sufficient thermal energy to jump across the band gap with increasing temperature. (1p) The reason for increasing resistivity of Ag is that the number of free charge carriers (conduction electrons) will not change, but the mobility μ_e will decrease because electrons will be scattered more strongly on atoms which due the higher temperature vibrate more heavily (electron/phonon interaction becomes stronger at higher temperatures). (1p)

c) Natural blue diamonds are semiconductors due to substitutional boron impurities replacing carbon atoms. Nowadays we can also make these semiconductors synthetically. What type of semiconductor do we have here, i.e., an electron or hole conductor? Explain why the resistivity of these boron doped diamond at room temperature can be many orders of magnitude lower than of pure diamond (which is transparent and colourless). (3p)

Boron doped diamond is a p-type semiconductor, i.e., a hole type conductor, because B has one valence electron less than C. (1p) The resistivity of these boron doped diamond can be many orders of magnitude lower than of pure diamond, because the boron atoms create an acceptor level in the band gap at an energy not much higher than the top of the valence band. Electrons from the C atoms can therefore jump easily into these acceptor level and leave holes behind which can travel relatively freely throughout the material. (1p) This is not possible in pure diamond, because its valence electrons have to jump across the total bandgap and thus need much more energy for this jump. At a certain limited temperature like room temperature thermal energy is thus sufficient to create a large number of charge carriers in B-doped diamond, whereas this is not possible for pure diamond. (1p)

- d) We have silicon doped with gallium, where on average for each 10⁷ crystal unit cells (lattice parameter of the cell $a_{Si}=0.543$ nm) 1 gallium atom is present. What type of semiconductor do we have here, i.e., intrinsic, extrinsic p-type or extrinsic n-type? At room temperature, the mobility of electrons $\mu_e = 0.19 \text{ m}^2/(\text{Vs})$ and of holes $\mu_h = 0.045 \text{ m}^2/(\text{Vs})$. The unit charge $e = -0.16 \times 10^{-18}$ C. Compute the conductivity of this semiconductor you expect at room temperature (e.g. in extrinsic temperature region). (3p) Ga-doped Si is a p-type extrinsic semiconductor, because Ga has one valence electron less than Si (1p). The expected conductivity at room temperature (all holes are activated) is: $\sigma = p|e|\mu_h = \frac{1}{10^7(0.543 \times 10^{-9})^3} \times 0.16 \times 10^{-18} \times 0.045 = 4.5 \ (\Omega m)^{-1}$. (2p)
- e) We now dope the sample of exercise d) (i.e., including the gallium atoms) with arsenic atoms such that 1 arsenic atom is added to each 2×10^7 unit cells. What type of semiconductor do we have now? Compute the conductivity you expect now at room temperature (where we assume that the additional arsenic doping does not affect the mobilities, although this is not strictly correct). (3p)

As is an n-type dopant that will compensate the p-type Ga. However, the amount of added As is only half of the amount of Ga. Therefore, the Si remains a p-type semiconductor (only in case the concentration of As would have been larger than of Ga it would change Si into n-type). (1p) Since only half of the holes remain uncompensated compared to question d), the conductivity becomes a factor 2 lower:

$$\sigma = p |e| \mu_h = \frac{1}{2 x 10^7 (0.543 x 10^{-9})^3} x \ 0.16 \ x 10^{-18} \ x \ 0.045 = 2.25 \ (\Omega m)^{-1} \ . \ (2p)$$

f) At room temperature the electrical conductivity and the electron mobility for Aluminium are $3.8 \times 10^7 (\Omega \text{ m})^{-1}$ and $0.0012 \text{ m}^2/(\text{V.s})$, respectively. Compute the number of free electrons per cubic meter for Aluminium at room temperature and determine the number of free electrons per one Aluminium atom?

Use for charge of single electron: -1.602 x10⁻¹⁹ C, Avogadro number $N_A = 6.022$ x10²³ atoms/mol, for density and atomic weight of Aluminium: $\rho' = 2.7$ g/cm³ and $A_{Al} = 26.98$ g/mol, respectively. (4p)

The number of free electrons per cubic meter for aluminium at room temperature may be computed using the equation:

$$n=\frac{o}{|e|\,\mu_e}=$$

$$=\frac{3.8 \, x 10^7 \, (\Omega \, . \, m)^{-1}}{(1.602 \, x 10^{-19} \, C) (0.0012 \, m^2 / (V \, . \, s))} = 1.98 \, x 10^{29} \, m^{-3} \quad (2p)$$

In order to calculate the number of free electrons per aluminium atom, we must first determine the number of aluminium atoms per cubic meter, N_{Al} :

$$N_{Al} = \frac{N_A \cdot \rho'}{A_{Al}} = \frac{(6.022 \, x 10^{23} \, atoms/mol). \, (2.7 \, g/cm^3). \, (10^6 \, cm^3/m^3)}{26.98 \, g/mol} =$$

$$= 6.03 \ x 10^{28} \ m^{-3}$$

And, finally the number of free electrons per copper atom is just n/N_{Cu} :

$$\frac{n}{N_{Al}} = \frac{1.98 \, x 10^{29} \, m^{-3}}{6.03 \, x 10^{28} \, m^{-3}} = 3.28. \quad (2p)$$

1				Atomic nu	mber	→1 											18 VIIIA
1	Name → Hydrogen										2 110						
H Hydrogen	en 1.008 - Atomic weight 2 Flettrons per shell 13 14 15 16 17											Helium 4.0026					
1	IIA			siectrons per	IIIA IVA VA VIA VIIA									2			
3 T 2	4 Po			Subcate	gory met	als, nonm	etals, and	metalloid	ls			5 D	Ċ	7 N	Ô	9	No
Lithium 6.94	Beryllium 9.013			Alkali m	etals	Lan	thanides		Metalloids Reactive non	motale		Boron 10.81	Carbon 12.011	Nitrogen 14.007	Oxygen 15.999	Fluorine 18.998	Neon 20.18
2-1	2-1			Alkaline	earth metals	Acti	inides		Neactive non	metals		2-3	2-4	2-5	2-6	2-7	2-8
Na	Mg			Transiti	on metals	Post	transition m	ietals	Unknown pro	operties		Al	Si	P	S	Cl	Ar
Sodium 22.98 2-8-1	Magnesium 24.32 2-8-2	3	4	5	6	7	8	9	10	11 12	12	Aluminium 26.98 2-8-3	Silicon 28.085 2-8-4	Phosphorus 30.97 2-8-5	Sulfur 32.06 2-8-6	Chlorine 35-45 2-8-7	Argon 39-95 2-8-8
19	20	21	22	23	24	25	26	27	28	29	30	31	32	33	34	35	36
K		Sc	Ti	V	Cr	Mn	Fe	Со	Ni	Cu	Zn	Ga	Ge	As	Se	Br	Kr
Potassium 39.10 2-8-8-1	Calcium 40.08	44.96 2-8-9-2	47.87 2-8-10-2	50.94 2-8-11-2	51.996 2-8-13-1	Manganese 54-94 2-8-13-2	55.84 2-8-14-2	Cobalt 55-93 2-8-15-2	55.69 2-8-16-2	63-55 2-8-18-1	63.38 2-8-18-2	69.72 2-8-18-3	72.63 2-8-18-4	74-92 2-8-18-5	74-92 2-8-18-6	79.90 2-8-18-7	83.80 2-8-18-8
37	38	39	40	41	42	43	44	45	46	47	48	49	50	51	52	53	54
Rb	Sr	Y	Zr	Nb	Мо	Тс	Ru	Rh	Pd	Ag	Cd	In	Sn	Sb	Те	Ι	Xe
Rubidium 85.47 2-8-18-8-1	Strontium 87.62 2-8-18-8-2	Yttrium 88.90 2-8-18-9-2	Zirconium 91.22 2-8-18-10-2	Niobium 92.90 2-8-18-12-1	Molybdenum 95-95 2-8-18-13-1	Technetium [98] 2-8-18-13-2	Ruthenium 101.07 2-8-18-15-1	Rhodium 102.91 2-8-18-16-1	Palladium 106.42 2-8-18-18	Silver 107.87 2-8-18-18-1	Cadmium 112.41 2-8-18-18-2	Indium 114.82 2-8-18-18-3	Tin 118.71 2-8-18-18-4	Antimony 121.76 2-8-18-18-5	Tellurium 127.60 2-8-18-18-6	Iodine 126.90 2-8-18-18-7	Xenon 131.29 2-8-18-18-8
55	56	57 - 71	72	73	74	75	76	77	78	80	80	81	82	83	84	85	86
Cs	Ba	Ln	Hf	Та	W	Re	Os	Ir	Pt	Au	Hg	Tl	Pb	Bi	Po	At	Rn
132.91 2-8-18-18-8-1	137-33 2-8-18-18-8-2	Lanthanides	178.49	Tantalum 180.95	183.84	Rhenium 186.21	0smium 190.23	192.22 2-8-18-22-15-2	195.08	Gold 196.97	200.59 2-8-18-32-18-2	204.38 2-8-18-32-18-3	207.2 2-8-18-32-18-4	208.98 2-8-18-32-18-5	[209] 2-8-18-32-18-6	[210] 2-8-18-32-18-7	[222] 2-8-18-32-18-8
87	88		104	105	106	107	108	109	110	111	112	113	114	115	116	117	118
Fr		89 - 103	Rf	Db	Sg	Bh	Hs	Mt	Ds	Rg	Cn	Nh	Fl	Mc	Lv	Ts	Og
Francium [223]	Radium [226]	Actinides	Rutherfordium [267]	[268]	[269]	Bohrium [270]	Hassium [277]	[278]	[281]	[282]	[285]	[286]	[289]	[290]	[293]	[294]	Oganesson [294]
2-8-18-32-18-8-1	2-8-18-32-18-8-2		2-8-18-32-32-10-2	2-8-18-32-32-11-2	2-8-18-32-32-12-2	2-8-18-32-32-13-2	2-8-18-32-32-14-2	2-8-18-32-32-15-2	2-8-18-32-32-16-2	2-8-18-32-32-17-2	2-8-18-32-32-18-2	2-8-18-32-32-18-3	2-8-18-32-32-18-4	2-8-18-32-32-18-5	2-8-18-32-32-18-6	2-8-18-32-32-18-7	2-8-18-32-32-18-8
		57	58	59	60	61	62	63	64	65	66	67	68	69	70	71	
		Lanthanum	Cerium	Pr	Nd	Pm Promethium	Samarium	Eu		Tb	Dy	Holmium	Er	Tm	Yb	Lu	
		138.91 2-8-18-18-9-2	140.12 2-8-18-19-9-2	140.91 2-8-18-21-8-2	144.24 2-8-18-22-8-2	[145] 2-8-18-23-8-2	150.36 2-8-18-24-8-2	151.96 2-8-18-25-8-2	157.25 2-8-18-25-9-2	158.93 2-8-18-27-8-2	162.50 2-8-18-28-8-2	164.93 2-8-18-29-8-2	167.26 2-8-18-30-8-2	168.93 2-8-18-31-8-2	173.05 2-8-18-32-8-2	174.97 2-8-18-32-9-2	
		89	90	91	92	93	94	95	96	97	98	99	100	101	102	103	
		Ac	Th	Pa	U	Np	Pu	Am	Cm	Bk	Cf	Es	Fm	Md	No	LW	
		[227]	232.04	231.04	238.03	[237]	[244]	[243]	[247]	[247]	[251]	[252]	[257]	[258]	[259]	[266] 2-8-18-32-32-8-3	
			10 34 10 10-2	100 44 100 44	100 40 10 40		10 Ja 24 84	Priyamstudycent	16.200		10 40 10 10 10		10 Ja (10 012	10.94.91.94			